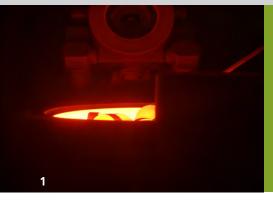


#### FRAUNHOFER INSTITUTE FOR ORGANIC ELECTRONICS, ELECTRON BEAM AND PLASMA TECHNOLOGY FEP







- 1 View on a heated crucible
- 2 3D model of an inductive single evaporation source
- 3 Example for the superposition of individual inductive evaporation sources for coating large web widths

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# INDUCTION EVAPORATION FOR THE COATING OF PLASTIC FILMS

# Motivation

Plastic films fulfil many functions in everyday life. They are used as food packaging; they build the basis for flexible solar cells or decorative films for furniture design. However, each film requires adapted coatings for various applications.

There are various processes for vacuum coating of plastic films, each of which is suitable for a specific application.

Particularly in the case of large-area coating, there are some disadvantages.

Electron beam evaporation, for example, is a relatively cost-intensive process and therefore not suitable for every application. In boat evaporation, mainly aluminum is evaporated, and sputtering processes are very time-consuming due to the lower coating rates.

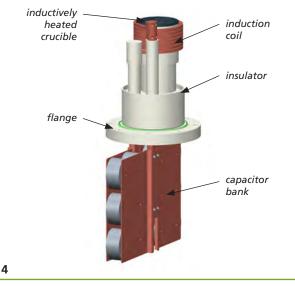
## **Technology**

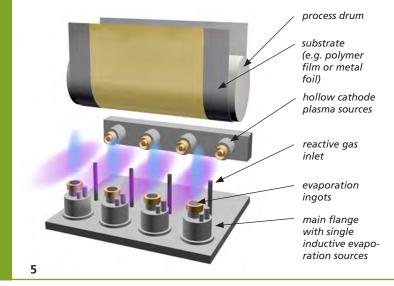
As a result, the Fraunhofer FEP has been working on an innovative and extremely flexible process for high rate deposition of substrates.

This new approach to induction evaporation consists essentially of inductively heated individual evaporation sources. Evaporator arrays can be realized via a modular design. Thus, large coating widths can be achieved by overlaying the individual coating areas.

Furthermore, various crucibles can be equipped, which offers the additional advantage of evaporating a wide range of materials.

The technology can also be combined with plasma sources and reactive gas systems.





This modular induction evaporation is fed by a power supply based on a novel inverter design for an adaptable and efficient energy coupling. This innovative power supply also provides interfaces for automated process control.

The high coating rates and the automated processes provide an efficient new process for large-area film coating.

#### **Materials**

- Aluminum
- Copper
- Silver
- Indium
- Silicon, silicon monoxide
- Lithium phosphorus oxinitrite (LiPON)

## **Applications**

- Flexible electronics
- Flexible solar cells
- Forgery protection
- Decorative films
- Packaging films
- Batteries

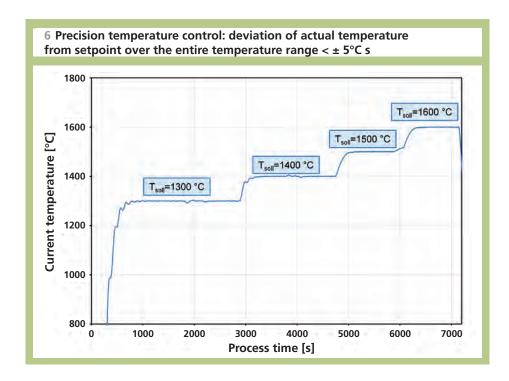
#### **Advantages**

- Flexibility through use of different materials
- Increase overall productivity through high coating rates and automated processes
- Possibility of combination with plasmaassisted methods
- Various film widths

#### Our services

Providing surfaces with tailor-made functions is the goal of our research and development work. Our offer includes all necessary steps from the concept phase up to the technology transfer:

- Feasibility studies
- Development of coating systems and customer-specific coating technologies
- Adaptation of existing coating lines
- Scaling up for large substrate areas, in-line systems and roll-to-roll systems
- Pilot production in the pilot phase of a product
- Technology transfer



- **4** 3D representation of an inductive single evaporation source
- 5 Example for the superposition of single inductive evaporation sources for the coating of large web widths



We focus on quality and the ISO 9001.